



# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE  
United States Patent and Trademark Office  
Address: COMMISSIONER FOR PATENTS  
P.O. Box 1450  
Alexandria, Virginia 22313-1450  
www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/812,347	03/30/2004	Fumihiko Higuchi	071469-0307558 (ES-038)	2682
7590 Eric Strang Suite 10 4350 W. Chandler Blvd. Chandler, AZ 85226		11/18/2008	EXAMINER CHEN, KIN CHAN	
			ART UNIT 1792	PAPER NUMBER
			MAIL DATE 11/18/2008	DELIVERY MODE PAPER

**Please find below and/or attached an Office communication concerning this application or proceeding.**

The time period for reply, if any, is set in the attached communication.

<b>Office Action Summary</b>	<b>Application No.</b>	<b>Applicant(s)</b>	
	10/812,347	HIGUCHI ET AL.	
	<b>Examiner</b>	<b>Art Unit</b>	
	Kin-Chan Chen	1792	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

#### Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

#### Status

1) Responsive to communication(s) filed on 01 October 2008.  
 2a) This action is **FINAL**.                    2b) This action is non-final.  
 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

#### Disposition of Claims

4) Claim(s) 1-22 and 24-30 is/are pending in the application.  
 4a) Of the above claim(s) 30 is/are withdrawn from consideration.  
 5) Claim(s) \_\_\_\_\_ is/are allowed.  
 6) Claim(s) 1-22 and 24-29 is/are rejected.  
 7) Claim(s) \_\_\_\_\_ is/are objected to.  
 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement.

#### Application Papers

9) The specification is objected to by the Examiner.  
 10) The drawing(s) filed on \_\_\_\_\_ is/are: a) accepted or b) objected to by the Examiner.  
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).  
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  
 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

#### Priority under 35 U.S.C. § 119

12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  
 a) All    b) Some \* c) None of:  
 1. Certified copies of the priority documents have been received.  
 2. Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.  
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

\* See the attached detailed Office action for a list of the certified copies not received.

#### Attachment(s)

1) Notice of References Cited (PTO-892)  
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  
 3) Information Disclosure Statement(s) (PTO/SB/08)  
 Paper No(s)/Mail Date 10242008.

4) Interview Summary (PTO-413)  
 Paper No(s)/Mail Date. \_\_\_\_\_.  
 5) Notice of Informal Patent Application  
 6) Other: \_\_\_\_\_.

## DETAILED ACTION

### ***Continued Examination Under 37 CFR 1.114***

A request for continued examination under 37 CFR 1.114 was filed in this application after a decision by the Board of Patent Appeals and Interferences, but before the filing of a Notice of Appeal to the Court of Appeals for the Federal Circuit or the commencement of a civil action. Since this application is eligible for continued examination under 37 CFR 1.114 and the fee set forth in 37 CFR 1.17(e) has been timely paid, the appeal has been withdrawn pursuant to 37 CFR 1.114 and prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submission filed on October 1, 2008 has been entered.

### ***Claim Rejections - 35 USC § 112***

1. Claim 29 is rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

In claim 29, line 11, "depends on a sensitivity" is new matter because it is not supported in the specification.

Claim 29 is rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

In claim 29, line 11, "depends on a sensitivity" is vague and indefinite because it is unclear what kind of sensitivity is referring to.

***Claim Rejections - 35 USC § 103***

2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

3. Claims 1-22 and 24-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tomoyasu et al. (US 2004/0185583; hereinafter "Tomoyasu").

In a method for chemical oxide removal, Tomoyasu (abstract; ([0007], [0059], [0074], [0200]; Fig. 2) teaches that a chemical oxide removal process may be performed using a process recipe including setting an amount of a first reactant, a second reactant such as NH<sub>3</sub>, HF, H<sub>2</sub>, O<sub>2</sub>, CO, CO<sub>2</sub>, Ar, He, see [0200]. Hence, it would have been obvious to one with ordinary skill in the art to **use these gases and combinations thereof**. Tomoyasu [0007, lines 4-5] teaches setting an amount of an

inert gas in order to achieve the trim amount. Tomoyasu teaches that the feature may be chemically treated by exposing the substrate to the process recipe and substantially removing the trim amount from the feature. Tomoyasu [0007] teaches the claimed variable parameters (setting a pressure, setting a temperature of substrate, setting a time period, setting a temperature of the process). Tomoyasu teaches changing flow rates of chemical treatment gases (e.g., gas flow rates of HF, NH<sub>3</sub>, or inert gas). Tomoyasu also teaches thermally treating the substrate and rinsing the substrate following the chemical treating. Tomoyasu ([0007], [0074]) teaches adjusting the amount of inert gas (gas flow rate) in order to remove the desired amount of the chemical oxide. Tomoyasu teaches using charts, and various models for analysis, therefore, hence, it would have been obvious to one with ordinary skill in the art to use curve fitting and polynomial expressions (claims 1, 12, 24-26) to determine the relationship. Tomoyasu clearly shows that process parameters and composition of chemical treatment gases are result-effective variables. The process of conducting routine experimentations so as to produce an expected result is obvious to one of ordinary skill in the art. In the absence of showing criticality or new, unexpected results, a person having ordinary skill in the art would have found it obvious to modify the prior art by performing routine experiments (by using different process parameters and compositions) to obtain optimal result with a reasonable expectation of success. As such, the relationship between a trim amount of the feature and an amount of an inert gas may be established. The relationship for an amount of first process gas, and an amount of second process gas, and trim amount may be determined.

**Changes in compositions, temperature, concentrations, or other process conditions of a process do not impart patentability unless the recited ranges are critical ( i.e., they produce a new and unexpected result that differs in kind and not merely in degree from the result of the prior art). *In re Woodruff*, 16USPQ2d 1934,1936 (Fed. Cir.1990); *In re Hoeschele*, 406 F.2d 1403, 160 USPQ 809; *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980). MPEP 2144.05 II.**

As discussed above, since the relationship between a trim amount of the feature and an amount of an inert gas and the process gas, and the relationship between a trim amount of the feature and process parameters may be established, it would have been obvious to one with ordinary skilled in the art to simply define various processing regimes, and determine the recipe for each process regime, and further obvious to one skilled in the art to use various names of process recipes such static recipe component and formula model component for different processing regimes, they are simply end-user defined for the steps in the design of experiment during the routine experimentation. **The examiner notes that in applicant's specification (e.g., paragraphs [0098]-[0100]) all said regimes and said names do not have any unique nor non-obvious functions other than the routine experimentation.**

As to dependent claims 11 and 21, see [0062].

As to dependent claim 22, Tomoyasu ([0007], [0074]) teaches adjusting the amount of inert gas (gas flow rate) in order to remove the desired amount of the chemical oxide, therefore, it is considered to read on claimed limitation.

The instant claims (claims 27 and 28) differ from Tomoyasu by specifying using the curve fitting including multiple regimes and using separate mass flow controller. However, Tomoyasu teaches using flow controller for the process gas. Using one controller or multiple controllers for the process is merely a matter of choices of engineering depending on product requirement, in the absence of unexpected result, it

would have been obvious to one with ordinary skill in the art to choose one or the other depending on the product requirement and quality criteria of the product.

4. Claims 1, 4-8, 10-12, 15-19, 21,22, and 24-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Newton et al. (US 2004/0099377; hereinafter "Newton").

In a method for chemical oxide removal, Newton (abstract; ([0026], [0033], [0057], [0073],[0074]), teaches that a chemical oxide removal process may be performed using a process recipe including setting an amount of a first reactant , a second reactant. Newton teaches setting an amount of an inert gas in order to achieve the trim amount. Newton teaches that the feature may be chemically treated by exposing the substrate to the process recipe and substantially removing the trim amount from the feature. Newton teaches the claimed variable parameters (setting a pressure, setting a temperature of substrate and setting a temperature of the process). Newton teaches changing process chemical treatment gas flow rates (e.g., gas flow rates of HF, NH<sub>3</sub>, or inert gas). As such, it would have been obvious to one with ordinary skilled in the art to determine the relationship between a trim amount of the feature and an amount of an inert gas. The relationship may be established for an amount of first process gas, and an amount of second process gas. The trim amount may be achieved by using the relationship. After gathering information of etching rates, thickness (trim amount), and process parameters, it would have been obvious to one with ordinary skill in the art to tabulate / extrapolate / manipulate data and perform calculation using

common engineering and statistical methods (such as regression, extrapolation, best-fit, polynomial, least squares, interpolation) and numerical analysis to optimize the relationship and minimize the error as instantly claimed (e.g., claims 1, 12, 24-26). Newton clearly shows that process parameters and composition of chemical treatment gases are result-effective variables. The process of conducting routine experimentations so as to produce an expected result is obvious to one of ordinary skill in the art. In the absence of showing criticality or new, unexpected results, a person having ordinary skill in the art would have found it obvious to modify the prior art by performing routine experiments (by using different process parameters and compositions) to obtain optimal result with a reasonable expectation of success.

**Changes in compositions, temperature, concentrations, or other process conditions of a process do not impart patentability unless the recited ranges are critical ( i.e., they produce a new and unexpected result that differs in kind and not merely in degree from the result of the prior art). *In re Woodruff*, 16USPQ2d 1934,1936 (Fed. Cir.1990); *In re Hoeschele*, 406 F.2d 1403, 160 USPQ 809; *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980). MPEP 2144.05 II.**

As discussed above, since the relationship between a trim amount of the feature and an amount of an inert gas and the process gas, and the relationship between a trim amount of the feature and process parameters may be established, it would have been obvious to one with ordinary skilled in the art to simply define various processing regimes, and determine the recipe for each process regime, and further obvious to one skilled in the art to use various names of process recipes such static recipe component and formula model component for different processing regimes, they are simply end-user defined for the steps in the design of experiment during the routine experimentation. The examiner notes that in applicant's specification (e.g., paragraphs

[0098]-[0100]) all said regimes and said names do not have any unique nor non-obvious functions other than the routine experimentation.

Claims 27 and 28 differ from prior art by specifying using the curve fitting including multiple regimes and using separate mass flow controller. However, Newton teaches using flow controller for the process gas. Using one controller or multiple controllers for the process is merely a matter of choices of engineering depending on product requirement, in the absence of unexpected result, it would have been obvious to one with ordinary skill in the art to choose one or the other depending on the product requirement and quality criteria of the product.

5. Claims 1, 4-12, and 15-22, and 24-29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Natzle et al. (US 2004/0097047; hereinafter "Natzle") in view of Newton et al. (US 2004/0099377; hereinafter "Newton").

In a method for chemical oxide removal, Natzle ([0014], [0037],[0038], [0042]-[0044]) teaches that a chemical oxide removal process may be performed using a process recipe including setting an amount of a first process gas and an amount of a second process gas. Natzle [0042] teaches acquiring data as a function of variable parameters (such as temperature, composition, residence time, pressure of the process gas, the amount of reactant or the rate of process gas), **all of which can be regulated**. Natzle teaches that the feature may be chemically treated by exposing the substrate to the process recipe and substantially removing the trim amount from the feature. Natzle

[0042] also discloses that the aforementioned variable parameters influence the amount removed.

The claimed invention differs from Natzle by specifying well-known feature of adding inert gas (argon) to the process gas. Newton ([0073][0074]) is relied on to show this feature. Hence, It would have found it obvious to incorporate inert gas to same in order to provide more uniform and stable etching with a reasonable expectation of success. As such, the adjustment of variable parameters discussed in Natzle is applicable in the combined Natzle and Newton. Thus, it would have been obvious to one with ordinary skilled in the art to determine the relationship between a trim amount of the feature and an amount of an inert gas. The relationship may be established for an amount of first process gas, and an amount of second process gas. The trim amount may be achieved by using the relationship.

As discussed above, since the relationship between a trim amount of the feature and an amount of an inert gas and the process gas, and the relationship between a trim amount of the feature and process parameters may be established, it would have been obvious to one with ordinary skilled in the art to simply define various processing regimes, and determine the recipe for each process regime, and further obvious to one skilled in the art to use various names of process recipes such static recipe component and formula model component for different processing regimes, they are simply end-user defined for the steps in the design of experiment during the routine experimentation. The examiner notes that in applicant's specification (e.g., paragraphs

[0098]-[0100]) all said regimes and said names do not have any unique nor non-obvious functions other than the routine experimentation.

As to dependent claim 11 and 21, see [0014].

After gathering information of etching rates, thickness (trim amount), and process parameters, it would have been obvious to one with ordinary skill in the art to tabulate / extrapolate / manipulate data and perform calculation using common engineering and statistical methods (such as regression, extrapolation, best-fit, polynomial, least squares, interpolation) and numerical analysis (e.g., claims 1, 12, and 24-26). Claims 27 and 28 differ from prior art by specifying using the curve fitting including multiple regimes and using separate mass flow controller. However, prior art teaches using flow controller for the process gas. Using one controller or multiple controllers for the process is merely a matter of choices of engineering depending on product requirement, in the absence of unexpected result, it would have been obvious to one with ordinary skill in the art to choose one or the other depending on the product requirement and quality criteria of the product.

6. Claims 2, 3, 13, and 14 are rejected under 35 U.S.C. 103(a) as being unpatentable over Natzle and Newton as applied to claims 1 and 12 above, and further in view of Doris et al. (US 2004/0241981; hereinafter "Doris").

The discussion of modified Natzle and Newton from above is repeated here.

Natzle and Newton are silent about the heating and rinsing with water after the chemical treating. In a method for chemical oxide removing, Doris teaches heating and

rinsing with water after the chemical treating so as to efficiently remove the solid reaction product, see [0046]. Hence, it would have been obvious to one with ordinary skill in the art to modify Natzle and Newton by heating and rinsing with water as taught by Doris in order to efficiently remove the solid reaction product.

### ***Response to Arguments***

7. Applicant's arguments filed October 1, 2008 have been fully considered but they are not persuasive.

Applicant has argued that prior art does not teach determining the relationship between a trim amount of the feature and an amount of an inert gas. The relationship may be established for an amount of a first process gas, and an amount of a second process gas. It is not persuasive. As has been stated in the office action, prior art clearly shows that process parameters and composition of chemical treatment gases are result-effective variables. The process of conducting routine experimentations so as to produce an expected result is obvious to one of ordinary skill in the art. In the absence of showing criticality or new, unexpected results, a person having ordinary skill in the art would have found it obvious to modify the prior art by performing routine experiments (by using different process parameters and compositions) to obtain optimal result with a reasonable expectation of success. As such, the relationship between a trim amount of the feature and an amount of an inert gas. The relationship may be established for an amount of a first process gas, and an amount of a second process may be determined.

**Changes in compositions, temperature, concentrations, or other process conditions of a process do not impart patentability unless the recited ranges are critical ( i.e., they produce a new and unexpected result that differs in kind and not merely in degree from the result of the prior art). *In re Woodruff*, 16USPQ2d 1934,1936 (Fed. Cir.1990); *In re Hoeschele*, 406 F.2d 1403, 160 USPQ 809; *In re Boesch*, 617 F.2d 272, 205 USPQ 215 (CCPA 1980). MPEP 2144.05 II.**

Applicant has argued that prior art does not teach different processing regimes, And the static recipe component and formula model component for different processing regimes. It is not persuasive. As has been stated in the office action, since the relationship between a trim amount of the feature and an amount of an inert gas and the process gas, and the relationship between a trim amount of the feature and process parameters may be established, it would have been obvious to one with ordinary skilled in the art to simply define various processing regimes, and determine the recipe for each process regime, and further obvious to one skilled in the art to use various names of process recipes such static recipe component and formula model component for different processing regimes, they are simply end-user defined for the steps in the design of experiment during the routine experimentation. **The examiner notes that in applicant's specification (e.g., paragraphs [0098]-[0100]) all said regimes and said names do not have any unique nor non-obvious functions other than the routine experimentation.** The examiner would like to remind applicant that mere reiteration of claim recitation (e.g., the prior art does not teach the names of process conditions; prior art does not teach the names of each section of the curve which defines the relationship ) does not constitute an argument within the meaning of 37 CFR 1.192(c) (7)(8). The argument needs to specify the errors in the rejection and the specific limitations in the rejected claims which are not described in the prior art relied upon in the rejection, and

an explanation **how such limitations render the claimed subject matter novel/unobvious over the prior art.**

8. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Kin-Chan Chen whose telephone number is (571) 272-1461. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on (571) 272-1465. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Kin-Chan Chen/  
Primary Examiner, Art Unit 1792

November 11, 2008